

Appl. No. 09/976,624

C1 105. (Amended) A method of forming a material adjacent a conductive electrical component comprising:

providing a mass adjacent the conductive electrical component, the mass comprising pores having a size and the mass comprising molecules consisting of silicon and carbon;

forming a layer overlying the mass; and

vaporizing a portion of the mass to expand the size of the pores within the mass.

111. (Amended) The method of Claim 105, further comprising forming a layer over the mass before the vaporizing.

112. (Amended) The method of Claim 105, further comprising forming a layer over the mass after the vaporizing.

113. (Amended) The method of Claim 105, where the conductive electrical component comprises a pair of conductive lines.

114. The method of Claim 113, further comprising forming at least one support member between the pair of conductive lines.

C2 130. (New) The method of claim 105 wherein the mass comprises SiC<sub>x</sub>.